Sheet 1 of 1 MIT.9944 10/632,442 FORM PTO-1449 SAMUELS, GAUTHIER & STEVENS LLP ATTORNEY DOCKET NO. SERIAL NO. (Rev. 5/92) 225 Franklin Street, Boston, MA 02110 SIPE Telephone: (617) 426-9180 APPLICANT: McGill et al. INFORMATION DISCLOSURE FILING DATE: August 1, 2003 TEB 2 6 2005 TA **EXAMINER: Unknown** TEMENT BY APPLICANT U.S. PATENT DOCUMENTS **EXAMINER** DOCUMENT FILING DATE INITIAL NUMBER IF APPROPRIATE DATE **CLASS SUBCLASS** NAME AA 2001/0028061 10/11/2001 Hosoba et al. 03/29/2001 AB 6,108,360 08/22/2000 Razeghi 06/06/1997 AC AD AE AF AG FOREIGN PATENT DOCUMENTS **EXAMINER** DOCUMENT TRANSLATION INITIAL NUMBER COUNTRY DATE **CLASS** SUBCLASS YES AΗ OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.) **EXAMINER** INITIAL "Evolution of microstructure and dislocation dynamics in In<sub>x</sub>Ga<sub>1-x</sub>P graded Buffers grown on GaP by metalorganic vapor phase epitaxy: engineering device-quality substrate materials," Kim et al. J. Vac. Sci. Technol. B. Jul/Aug 1999. Vol. 17. "Yellow-Green emission for ETS-LEDs and Lasers based on a strained InGaP quantum well heterostructure grown on a transparent, compositionally graded AlInGaP buffer," McGill et al. Mat. Res. Soc. Symp. 2003: Vol. 744. AI. AM AN

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GROUP: Unknown

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